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A mild and fast photocatalytic trifluoromethylation of thiols in batch and continuous-flow[†]

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 $S-CF_3$ bonds are important structural motifs in various pharmaceutical and agrochemical compounds. However, their preparation remains a major challenge in synthetic organic chemistry. Here, we report the development of a mild and fast photocatalytic trifluoromethylation of thiols. The combination of commercially available $Ru(bpy)_3Cl_2$, visible light and inexpensive CF_3I gas proved to be an efficient method for the direct trifluoromethylation of thiols. The protocol is demonstrated on a wide range of aromatic, hetero-aromatic and aliphatic substrates in both batch and continuous microflow (32 examples, 52-98% yield). Process intensification through continuous microflow application resulted in a 15-fold increase in production rate (0.25 mmol min⁻¹) due to improved gas–liquid mass transfer, enhanced irradiation as well as convenient handling of the gaseous CF_3 source. Furthermore, the efficiency of the flow process allowed to reduce the amount of CF_3I (1.1 equivalent) to reach full conversion.

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Introduction

The development of mild methods regarding the incorporation of fluorine-containing functional groups has gained increasing attention.1 This is undoubtedly driven by the growing demand in the pharmaceutical and agrochemical industry, as well as its increasing need for the development of ¹⁸F-labeled organic compounds for positron emission tomography (PET) imaging.² In particular, the incorporation of trifluoromethyl moieties (CF₃) has been widely investigated on e.g. alkenes, arenes and hetero-arenes.3 In contrast, the trifluoromethylation of thiols (S-CF₃) is much less developed.⁴ The incorporation of a trifluoromethylthio (S-CF₃) motif in a drug molecule results in an extremely high lipophilicity (Hansch parameter, $\pi_{\rm R} = 1.44$) and improves the stability of the molecule in acidic media. Access to such compounds is crucial since they constitute a key intermediate for the synthesis of biologically active (trifluoromethyl)-sulfoxides and sulfones.

Reported Direct Trifluoromethylation of Benzenethiols Methods (Eq. 1)



Construction of Thioethers via Photocatalytic Aryl Radical Generation (Eq. 2)



Direct Trifluoromethylation of Thiols via Photocatalytic ${\rm CF}_3^{\,\bullet}$ Generation (This work) (Eq. 3)



To date, a number of methods have been developed for the construction of S–CF₃ bonds *via* direct trifluoromethylation of readily accessible aryl and alkyl thiols.⁵ These bonds can be constructed *via* an ion-radical mechanism employing inexpensive CF₃ sources such as CF₃I or CF₃Br.^{6,7} However, most of these methods, if not all, suffer from limited substrate scope, prolonged reaction times and require harsh conditions, such as the use of liquid ammonia as a solvent system, elevated pressure and the use of UV light (eqn (1)). A more convenient





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radical-chain approach via a single electron transfer (SET) was reported by Koshechko and coworkers but still rendered a very limited scope and relative long reaction times.8 More recently, great effort was conducted in the development of shelf-stable CF_3 -electrophilic (CF_3^+) reagents, such as Umemoto's reagent⁹ and Togni's reagent.¹⁰ These reagents are well-known and easyto-handle trifluoromethylating agents and demonstrate good selectivity and broad substrate scope. However, commercial sources of these reagents are expensive, and the preparation requires multiple synthetic steps, making them less attractive for scale-up.¹¹ In contrast, radical CF₃ sources, such as CF₃I (bulk chemical) or triflyl chloride (CF₃SO₂Cl), would be more advantageous to use given their low cost price and availability. In search of a mild and broadly applicable method for the trifluoromethylation of thiols, we turned our attention to the use of visible-light photoredox catalysis.12 Visible-light photoredox catalysis has emerged as a mild and efficient method to functionalize molecules and is tolerant to a broad range of functional groups. Recently, we have established the efficient and mild formation of C-S bonds via a photocatalytic Stadler-Ziegler reaction.13 Hereby, aryl radicals are generated from in situ prepared diazonium salts which subsequently react with thiols to generate the required C-S linkage (eqn (2)).14 We anticipated that a similar strategy could be exploited for the trifluoromethylation of thiols, thereby rendering a more general and practical approach to the formation of RS-CF₃ compounds (eqn (3)). Furthermore, the use of CF_3I , as an inexpensive, stable and widely available CF3 source, makes our method cost-efficient.15 Taking advantage of continuous-flow photochemistry, we were able to accelerate the developed S-CF₃ protocol significantly to increase its throughput and scalability.16

Results and discussion

The proposed trifluoromethylation strategy was first evaluated with thiophenol, Ru(bpy)₃Cl₂, and a 24 W fluorescent lamp (Table 1). Both CF₃I and CF₃SO₂Cl were used as a CF₃ source (Table 1, entries 1–3). In the absence of any additive, only a trace amount of the desired compound (1b) could be observed, while the major reaction was the formation of diphenyl disulfide (1c). A high selectivity for the disulfide product was found when CF₃SO₂Cl was used, which also occurred in the absence of a photocatalyst. The use of an organic base effectively suppressed by-product formation (Table 1, entries 4-8).17 Optimal conditions were obtained when 2.0 equivalents of triethylamine (TEA) was introduced to the reaction, resulting in the selective trifluoromethylation of thiophenol within one hour. Further, only a slight excess (1.1 equiv.) of TEA was required to obtain full conversion of thiophenol (Table 1, entries 9-10). Control experiments established the necessity of both the photoredox catalyst and the presence of visible light (Table 1, entries 11–12), as a high degree of disulfide formation or no reaction was observed in both these cases. The formation of the SCF₃product in the absence of a photocatalyst occurs through homolysis of CF₃I upon irradiation.¹⁸

With the optimized conditions in hand, we set out to explore the scope of this photocatalytic transformation. A broad array of aromatic thiols, heteroaromatic thiols and aliphatic thiols were subjected to our optimized trifluoromethylation protocol (Scheme 1). Aromatic thiols bearing electron-withdrawing and electron-donating functional groups were all competent substrates. Notably, most examples could be finished within one hour reaction time (Scheme 1). As expected, aromatic thiols with strong electron-withdrawing functional groups reacted much slower (up to 5 hours reaction time) but were still obtained in moderate to good yields (Scheme 1, examples 6b, 8b, 18b). The mildness of our protocol is exemplified by its tolerance towards aromatic thiols bearing a free carboxylic acid, an alcohol, or an amine (Scheme 1, examples 9b, 15b, 19b). In addition, the presence of chlorine and bromine substituents was well tolerated providing opportunities for orthogonal selectivity with cross-coupling chemistry (Scheme 1, examples 11b and 12b). These representative examples illustrate the general applicability of our method to prepare S-CF₃ bearing aromatic compounds by photocatalytic trifluoromethylation of aromatic thiols.

Encouraged by these results, we extended our investigations towards the photocatalytic trifluoromethylation of heteroaromatic thiols (Scheme 1, examples 20-26b). 2-Mercaptopyridine, 4-mercaptopyridine, 2-mercaptobenzoxazole, 2-mercaptobenzothiazole, unprotected and protected 2-mercaptobenzimidazole and 2-mercaptopyrimidine could be efficiently trifluoromethylated within one hour reaction time under the given conditions. It should be noted that extended reaction times resulted in lower selectivity for the desired compound through the incorporation of additional CF3-groups on the aromatic ring.19 Aliphatic thiols proved to be the most challenging substrate class (Scheme 1, examples 27-29b). Under the established reaction conditions, the formation of the corresponding disulfides could not be prevented. This could be partially overcome by an in situ reduction of the formed disulfide by adding triphenylphosphine and water.20

During the course of our investigations, we observed that the rate of the reaction in batch is affected by the mixing efficiency. To establish a better contact between gaseous CF3I and the liquid reaction mixture in batch, CF₃I was added via syringe pump and bubbled through the reaction mixture in 10 minutes. A further increase in interfacial area between gaseous CF₃I and liquid reaction mixture can be obtained in continuous-flow microreactors.²¹ In such devices, gas-liquid flow results in the formation of a segmented flow regime which provides an intense contact between liquid and gas phase. Furthermore, process intensification of photochemical transformations can be efficiently achieved in microreactors.16,22 The observed intensification is a consequence of the improved irradiation of the reaction medium in such confined reactors, which leads to a more uniform local volumetric rate of energy absorption.23 The microflow setup consists of a high purity perfluoroalkoxyalkane (PFA) capillary microreactor (500 µm ID, 2.5 m length, 500 µL volume) and a Tefzel cross-mixer, which was connected to a CF₃I gas cylinder and two syringes containing the liquid reagents (Fig. 1). CF₃I was dosed into the reactor system by means of a mass flow controller (MFC). The liquid reagents were added by syringe pump and upon

Table 1 Optimization of reaction conditions^e



Entry ^a	Catalyst	Additive (equiv.)	CF ₃ I		CF ₃ SO ₂ Cl	
			$\operatorname{Conv.}^{b}(\%)$	Yield $[\mathbf{1b}:\mathbf{1c}]^{b}$ (%)	Conv. $(\%)^b$	Yield $[\mathbf{1b}:\mathbf{1c}]^{b}$ (%)
1	Ru(bpy) ₃ Cl ₂	_	35	Trace : 33	98	0:98
2	Ir(ppy) ₃	_	22	Trace : 21	100	0:89
3	Ir(F-ppy) ₃	_	26	Trace : 25	100	5:75
4	$Ru(bpy)_3Cl_2$	Py (2)	72	4:68	_	_
5	$Ru(bpy)_3Cl_2$	TEA(2)	100	97:3	_	_
6	$Ru(bpy)_3Cl_2$	DIPEA (2)	100	99:1	_	_
7	$Ru(bpy)_3Cl_2$	DBU (2)	100	100:0	_	_
8	$Ru(bpy)_3Cl_2$	TMEDA (2)	100	99:1	_	_
9	$Ru(bpy)_3Cl_2$	TEA (1.1)	100	100:0	_	_
10	$Ru(bpy)_3Cl_2$	TEA (0.5)	76	75:1	_	_
11 ^c	none	TEA (1)	100	55:45	—	_
12^d	$Ru(bpy)_3Cl_2$	TEA (1)	0	0:0	_	_

^{*a*} Reaction conditions: thiophenol (1 mmol), CF₃I (4 mmol) or CF₃SO₂Cl (1.2 mmol), photoredox catalyst (1 mol%), MeCN (5 mL), CFL (24 W), room temperature, 1 hour. ^{*b*} Conversion and yield of **1b** and **1c** are determined by GC and ¹⁹F-NMR. ^{*c*} Absence of photocatalyst showed rapid disulfide formation. ^{*d*} Reaction carried out in the dark. ^{*e*} Abbreviations: bpy: bipyridine, ppy: phenylpyridine, F-ppy: 3,5-difluorophenylpyridine, Py: pyridine, TEA: triethylamine, DIPEA: (diisopropyl)ethylamine, DBU: 1,8-diazobicyclo[5.4.0]undec-7-ene, TMEDA: tetramethylethane-1,2-diamine.



Scheme 1 Substrate scope for photocatalytic direct trifluoromethylation. [Section A] Aryl thiols (compounds 1b-19b), [Section B] heteroaryl thiols (compounds 20b-26b) and [Section C] aliphatic thiols (27b-29b). [a] Batch protocol: thiol (1 mmol), Ru(bpy)₃Cl₂ (0.01 mmol), CF₃I (4 mmol) in MeCN (5 mL). Then add TEA (1.1 mmol) and irradiate with a 24 W CFL household light bulb at room temperature. Reported yields are those of isolated compounds or calculated with 19F-NMR with internal standard for volatile compounds. See ESI† for more details. [b] Flow protocol: thiol (1 mmol), Ru(bpy)₃Cl₂ (0.01 mmol), CF₃I (1.1 mmol), TEA (1.1 mmol) in MeCN are mixed *via* a cross-mixer and irradiated with an array of 3.12 W Blue LED's. [c] Additives Ph₃P/H₂O (1 : 1, 1 equiv.) were added.



Fig. 1 Continuous-flow setup for the visible-light photocatalytic trifluoro-methylation of thiols.

merging with gaseous $CF_{3}I$, a segmented gas-liquid flow was established. The reaction mixture was exposed to blue LED irradiation which matches the absorption maximum of the photocatalyst. Nine different thiols, including aryl, heteroaryl and alkyl thiols, were evaluated in our continuous-flow system (Scheme 1).

A significant acceleration could be observed in all cases; several examples could be completed within one minute residence time (Scheme 1, examples **1b**, **10b**, **11b**, **14b**, **15b**, **20b**). Thiophenols bearing electron-withdrawing functional groups could be accelerated, however, it was difficult to reach complete conversion within 30 minutes residence time (Scheme 1, example **18b**). A substantial increase was observed for cyclohexylthiol (Scheme 1, example **28b**). Importantly, it should be noted that the required amount of CF_3I gas could be drastically reduced in flow to 1.1 equivalents (4 equivalents in batch) due to the improved contact between the gas and liquid reactants in the photomicroreactor.

So far, we only used thiols as substrates for the formation of trifluormethylthio compounds. As was demonstrated with aliphatic thiols, disulfide by-products can be *in situ* reduced by the triphenylphosphine/water system and allowed to produce the desired S–CF₃ products. Utilizing this protocol, disulfides could be directly used as substrates for the trifluoromethylation protocol (see Scheme 2, eqn (4)).

The products of this photocatalytic trifluoromethylation of thiols may serve as useful synthetic intermediates towards interesting biologically active compounds. To demonstrate this, compound 7**b** was oxidized to yield the corresponding sulfoxide (Scheme 2, eqn (5a)). Furthermore, as demonstrated above, reductive dehalogenation was not observed under the current reaction conditions. This feature allows to further decorate the molecule by *e.g.* cross-coupling chemistry (Scheme 2, eqn (5b)).

We next examined the structural diversity of the perfluoroalkyl halide coupling partner in this photocatalytic protocol. Efficient coupling could be achieved with ethyl 2-bromo-difluoroacetate, perfluorohexyliodide and perfluorobutyliodide as representative examples (Scheme 2, below). The coupling with ethyl 2-bromo-difluoroacetate gives rise to a versatile intermediate (**30b**) which can be used to introduce ¹⁸F *via* a Ag-catalyzed decarboxylative fluorination.²⁴ The possibility to prepare perfluoroalkyl analogues represents a significant advantage of our method compared to the use of perfluoroalkyl electrophilic reagents, which are either expensive, not commercially available, or difficult to synthesize.



Scheme 2 Synthetic applications of the photocatalytic trifluoromethylation protocol. (i) Use of disulfides as a substrate (eqn (4)); (ii) formation of sulfoxides *via* a one-pot photocatalytic trifluoromethylation/oxidation sequence (eqn (5a)), and exploitation of the orthogonal selectivity between photoredox catalysis and crosscoupling chemistry (eqn (5b)); (iii) photocatalytic perfluoroalkylation of aryl thiols.

A plausible mechanism for the photocatalytic trifluoromethylation of thiols is depicted in Fig. 2. Reductive quenching of the exited state of $\text{Ru}(\text{bpy})_3^{2+*}$ occurs *via* a nitrogen base. Replacing the nitrogen base by an inorganic base, *i.e.* K₂HPO₄, resulted in the exclusive formation of disulfide with no S–CF₃ bond formation (see ESI†).²⁵ This observation supports the necessity of a reductive quencher to obtain the desired product.²⁶ Next, oxidizing the [Ru(bpy)₃]⁺ species to its ground state generates an electrophilic CF₃ radical.¹⁵ This CF₃ radical can subsequently react with the thiol substrate to yield the desired S–CF₃ product.



Fig. 2 Proposed mechanism for the photocatalytic trifluoromethylation of thiols.

Conclusions

In conclusion, we have developed a mild and fast photocatalytic approach to the direct trifluoromethylation of thiols. The method was shown to have a broad substrate scope allowing for the preparation of aryl, heteroaryl and alkyl S-CF₃ compounds in good-to-excellent yields. Furthermore, our protocol allows for variation of the perfluoroalkyl halide coupling partner giving rise to perfluoroalkylated thiophenols. Acceleration of the photocatalytic protocol was achieved in a continuous-flow photomicroreactor (reaction times can be reduced to the minute range). Most notably, only a slight excess of CF₃I (1.1 equivalents) was required in the continuous-flow experiments due to excellent gas-liquid mass transfer characteristics. Given the operational simplicity of both batch and flow protocols, we anticipate that our photocatalytic method for the trifluoromethylation of thiols will find broad application in academia and industry.

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Notes and references

- 1 (a) P. Kirsch, Modern Fluoroorganic Chemistry: Synthesis Reactivity & Applications, Wiley-VCH, Weinheim, 2004; (b) J.-P. Bégué and D. Bonnet-Delpon, Bioorganic and Medical Chemistry of Fluorine, Wiley-VCH, Hoboken, 2008.
- 2 (a) K. Muller, C. Faeh and F. Diederich, Science, 2007, 317, 1881–1886; (b) S. Purser, P. R. Moore, S. Swallow and V. Gouverneur, Chem. Soc. Rev., 2008, 37, 320–330; (c) P. W. Miller, N. J. Long, R. Vilar and A. D. Gee, Angew. Chem., Int. Ed., 2008, 47, 8998–9033; (d) J. Wang, M. Sanchez-Rosello, J. L. Acena, C. del Pozo, A. E. Sorochinsky, S. Fustero, V. A. Soloshonok and H. Liu, Chem. Rev., 2014, 114, 2432–2506.
- 3 For recent reviews regarding trifluoromethylation or perfluoroalkylation, see: (a) T. Furuya, A. S. Kamlet and T. Ritter, *Nature*, 2011, 473, 470–477; (b) O. A. Tomashenko and V. V. Grushin, *Chem. Rev.*, 2011, 111, 4475–4521; (c) Y. Macé and E. Magnier, *Eur. J. Org. Chem.*, 2012, 2479–2494; (d) A. Studer, *Angew. Chem., Int. Ed.*, 2012, 51, 8950–8958; (e) H. Liu, Z. Gu and X. Jiang, *Adv. Synth. Catal.*, 2013, 355, 617–626; (f) X. Liu, M. Wang and Q. Liu, *Chem. Rev.*, 2014, DOI: 10.1021/cr400473a.
- 4 L. Chu and F.-L. Qing, *Acc. Chem. Res.*, 2014, 47, 1513–1522.
 (a) G. Landelle, A. Panossian, S. Pazenok, J. P. Vors and F. R. Leroux, *Beilstein J. Org. Chem.*, 2013, 9, 2476–2536; (b) V. N. Boiko, *Beilstein J. Org. Chem.*, 2010, 6, 880–921.
- 5 For selected reports on the direct trifluoromethylation: (a) R. Pluta, P. Nikolaienko and M. Rueping, *Angew. Chem.*,

Int. Ed., 2014, **53**, 1650–1653; (*b*) F. Hu, X. Shao, D. Zhu, L. Lu and Q. Shen, *Angew. Chem., Int. Ed.*, 2014, **53**, 6105–6109; (*c*) S. Alazet, L. Zimmer and T. Billard, *Angew. Chem., Int. Ed.*, 2013, **52**, 10814–10817. For a mini-review on direct trifluoromethylthiolation: ; (*d*) A. Tlili and T. Billard, *Angew. Chem., Int. Ed.*, 2013, **52**, 6818–6819.

- 6 (a) V. N. Boiko, G. M. Shchupak and L. M. Yagupolskii, *Zh. Org. Khim.*, 1977, 13, 1057–1061; (b) V. N. Boiko, T. A. Dashevskaya, G. M. Shchupak and L. M. Yagupolskii, *Zh. Org. Khim.*, 1979, 15, 396–400; (c) V. N. Boiko, G. M. Shchupak and L. M. Yagupolskii, *Zh. Org. Khim.*, 1985, 21, 1470–1477.
- 7 T. Billard, N. Roques and B. R. Langlois, *J. Org. Chem.*, 1999, **64**, 3813–3820.
- 8 (a) V. G. Koshechko, L. A. Kiprianova and L. I. Fileleeva, *Tetrahedron Lett.*, 1992, 33, 6677–6678; (b) V. G. Koshechko,
 L. A. Kiprianova, L. I. Fileleeva and Z. Z. Rozhkova, J. *Fluorine Chem.*, 1995, 70, 277–278; (c) V. G. Koshechko,
 L. A. Kiprianova, L. I. Fileleeva and K. G. Tsanov, J. Fluorine Chem., 1999, 96, 163–166.
- 9 T. Umemoto and S. Ishihara, J. Am. Chem. Soc., 1993, 115, 2156-2164.
- 10 (a) P. Eisenberger, S. Gischig and A. Togni, *Chem.-Eur. J.*, 2006, 12, 2579–2586; (b) I. Kieltsch, P. Eisenberger and A. Togni, *Angew. Chem., Int. Ed.*, 2007, 46, 754–757.
- 11 T. Umemoto, Chem. Rev., 1996, 96, 1757-1778.
- 12 For selected reviews about photoredox catalysis: (a)
 K. Zeitler, Angew. Chem., Int. Ed., 2009, 48, 9785–9789; (b)
 J. W. Tucker and C. R. J. Stephenson, J. Org. Chem., 2012, 77, 1617–1722; (c)
 C. K. Prier, D. A. Rankic and D. W. C. MacMillan, Chem. Rev., 2013, 113, 5322–5363; (d)
 D. A. Nicewicz and T. M. Nguyen, ACS Catal., 2014, 4, 355–360.
- 13 X. Wang, G. D. Cuny and T. Noël, Angew. Chem., Int. Ed., 2013, 52, 7860–7864.
- 14 For a report with disulfides as reaction partner: M. Majek and A. J. von Wangelin, *Chem. Commun.*, 2013, **49**, 5507– 5509.
- 15 For recent developments on C-CF3 bond formations via photoredox catalysis utilizing CF₃I, see: (a)N. J. W. Straathof, H. P. L. Gemoets, X. Wang, J. C. Schouten, V. Hessel and T. Noël, ChemSusChem, 2014, 7, 1612-1617; (b) N. J. W. Straathof, D. J. G. P. van Osch, A. Schouten, X. Wang, J. C. Schouten, V. Hessel and T. Noël, J. Flow Chem., 2014, 4, 12-17; (c) N. Iqbal, J. Jung, S. Park and E. J. Cho, Angew. Chem., Int. Ed., 2014, 53, 539-542; (d) E. Kim, S. Choi, H. Kim and E. J. Cho, Chem.-Eur. J., 2013, 19, 6209-6212; (e) N. Iqbal, S. Choi, E. Kim and E. J. Cho, J. Org. Chem., 2012, 77, 11383-11387; (f) Y. Ye and M. S. Sanford, J. Am. Chem. Soc., 2012, 134, 9034-9037; (g) P. V. Pham, D. A. Nagib and D. W. C. MacMillan, Angew. Chem., Int. Ed., 2011, 50, 6119-6122; (h) D. A. Nagib, M. E. Scott and D. W. C. MacMillan, J. Am. Chem. Soc., 2009, 131, 10875-10877.
- 16 For reviews pertaining the combination of continuous-flow microreactors and photochemistry: (*a*) T. Noël, X. Wang and V. Hessel, *Chim. Oggi*, 2013, **31**, 10–14; (*b*)

M. Oelgemöller, *Chem. Eng. Technol.*, 2012, **35**, 1144–1152; (*c*) J. P. Knowles, L. D. Elliott and K. I. Booker-Milburn, *Beilstein J. Org. Chem.*, 2012, **8**, 2025–2052; (*d*) M. Oelgemoeller and O. Shvydkiv, *Molecules*, 2011, **16**, 7522–7550; (*e*) E. E. Coyle and M. Oelgemoeller, *Photochem. Photobiol. Sci.*, 2008, 7, 1313–1322; (*f*) Y. Matsushita, T. Ichimura, N. Ohba, S. Kumada, K. Sakeda, T. Suzuki, H. Tanibata and T. Murata, *Pure Appl. Chem.*, 2007, **79**, 1959–1968; (*g*) Z. J. Garlets, J. D. Nguyen and C. R. J. Stephenson, *Isr. J. Chem.*, 2014, **54**, 351–360; (*h*) E. M. Schuster and P. Wipf, *Isr. J. Chem.*, 2014, **54**, 361–370.

- 17 It should be noted that the use of 1,8-diazabicyclo[5.4.0] undec-7-ene (DBU) darkened the reaction mixture, which lengthened the reaction times due to inefficient irradiation.
- 18 M. R. Nyden, in *Fire suppression system performance of alternative agents in aircraft engine and dry bay laboratory systems*, ed. R. G. Gann, 1995, pp. 77–95, NIST SP 890.
- 19 D. A. Nagib and D. W. C. MacMillan, *Nature*, 2011, **480**, 224–228.
- 20 R. E. Humphrey and J. M. Hawkins, Anal. Chem., 1964, 36, 1812–1814.
- 21 T. Noël and V. Hessel, ChemSusChem, 2013, 6, 405-407.
- 22 For selected reports on the merger of visible-light photoredox catalysis and continuous-flow microreactors:

- (a) D. Cantillo, O. de Frutos, J. A. Rincon, C. Mateos and C. O. Kappe, Org. Lett., 2014, 16, 896-899; (b)
 A. C. Hernandez-Perez and S. K. Collins, Angew. Chem., Int. Ed., 2013, 125, 12928-12932; (c)
 M. Neumann and K. Zeitler, Org. Lett., 2012, 14, 2658-2661; (d) J. W. Tucker, Y. Zhang, T. F. Jamison and C. R. J. Stephenson, Angew. Chem., Int. Ed., 2012, 51, 4144-4147; (e) See also ref. 13, 15a and b ; (f) For reviews on visible-light photoredox catalysis in flow, see: ref. 16a and g.
- 23 Y. Su, N. J. W. Straathof, V. Hessel and T. Noël, *Chem.-Eur. J.*, 2014, **20**, 10562–10589.
- 24 (a) S. Mizuta, I. S. R. Stenhagen, M. O'Duill, J. Wolstenhulme, A. K. Kirjavainen, S. J. Forsback, M. Tredwell, G. Sandford, P. R. Moore, M. Huiban, S. K. Luthra, J. Passchier, O. Solin and V. Gouverneur, *Org. Lett.*, 2013, 15, 2648–2651; (b) M. Huiban, M. Tredwell, S. Mizuta, Z. Wan, X. Zhang, T. L. Collier, V. Gouverneur and J. Passchier, *Nat. Chem.*, 2013, 5, 941–944.
- 25 For a comprehensive discussion of photocatalytic disulfide formation, we refer to: A. Talla, B. Driessen, N. J. W. Straathof, L.-G. Milroy, L. Brunsveld, V. Hessel, X. Wang, T. Noël, 2014, submitted for publication.
- 26 L. Furst, B. S. Matsuura, J. M. R. Narayanam, J. W. Tucker and C. R. J. Stephenson, *Org. Lett.*, 2010, **12**, 3104–3107.